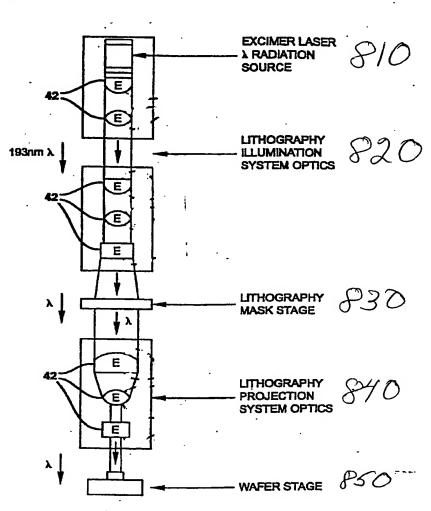


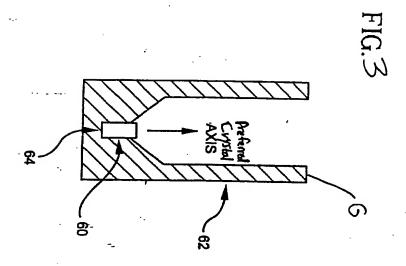


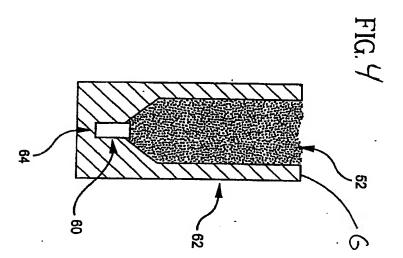
: .

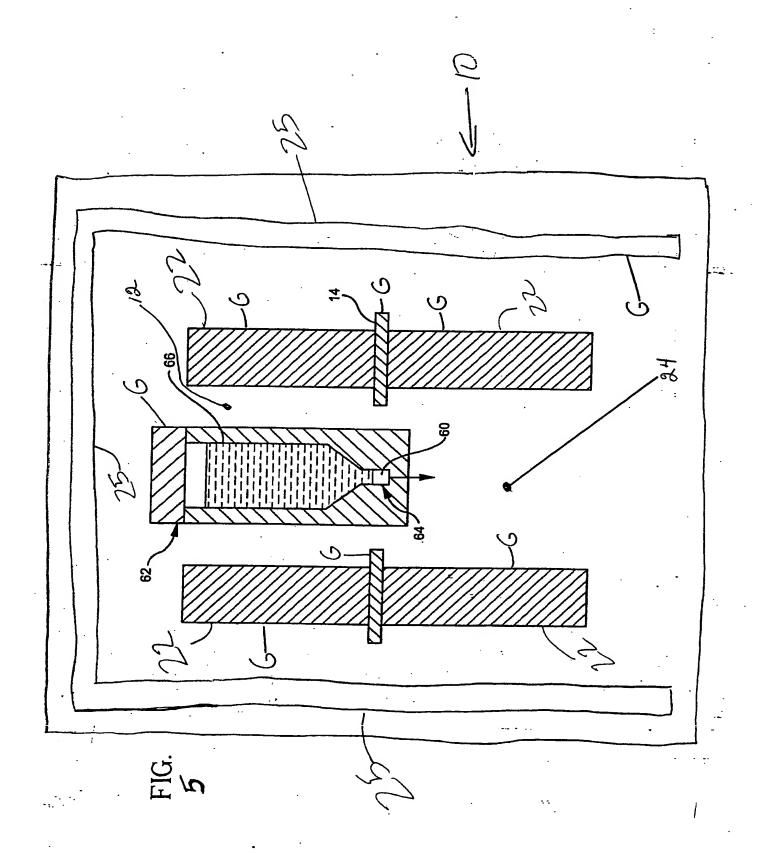
• •

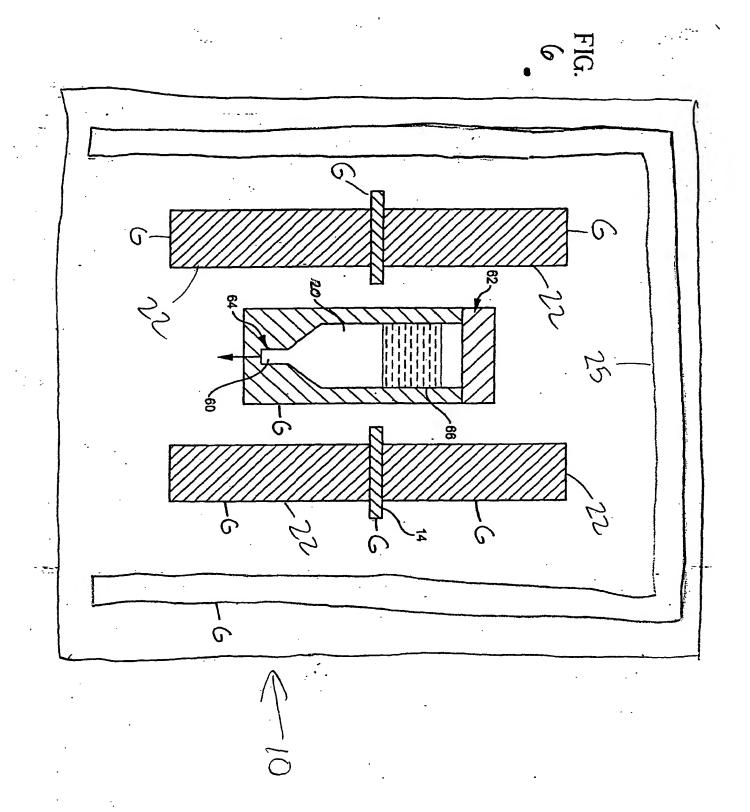


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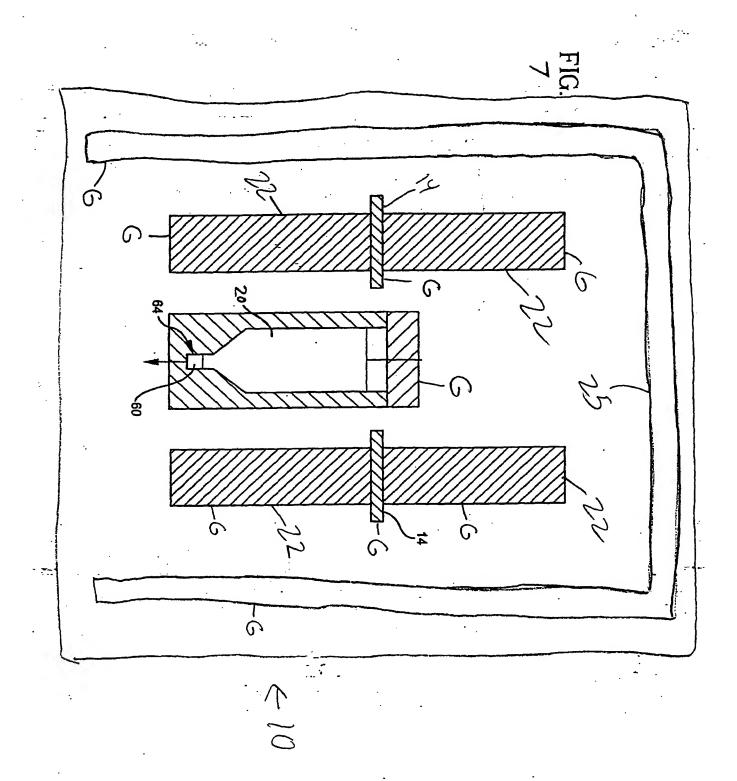
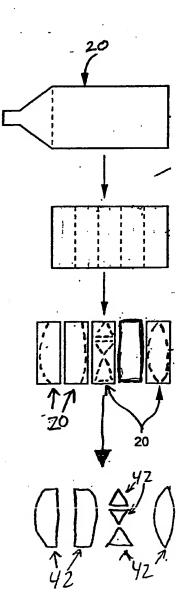


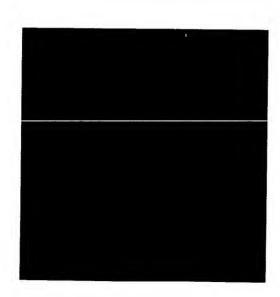
FIG. 8



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FIG. 9B

FIG. 9A



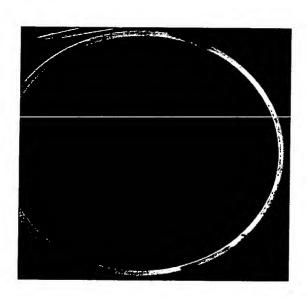
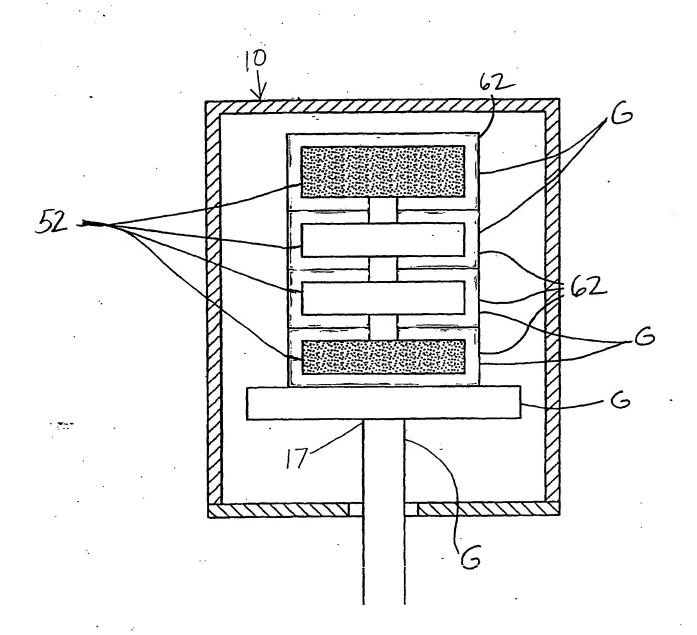


FIG.10



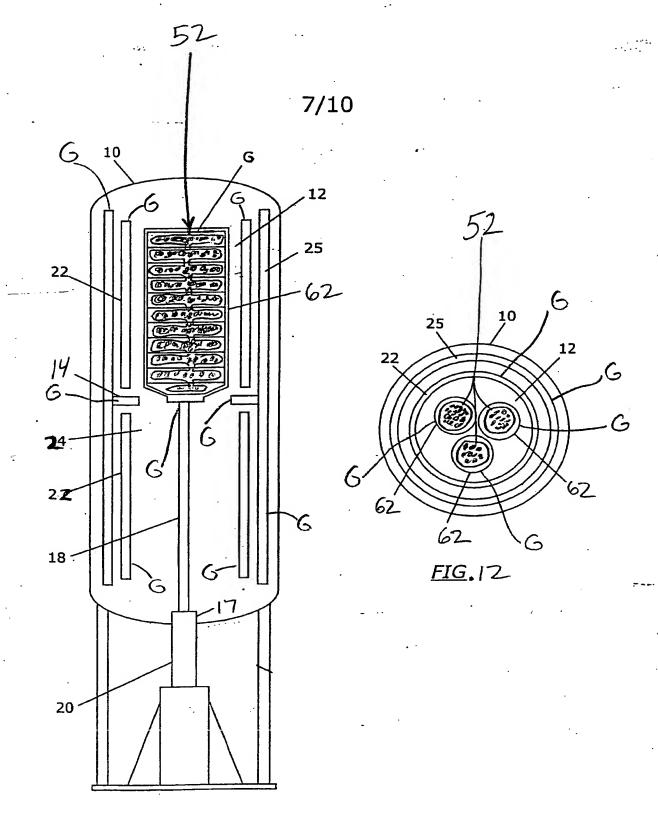


FIG. 1

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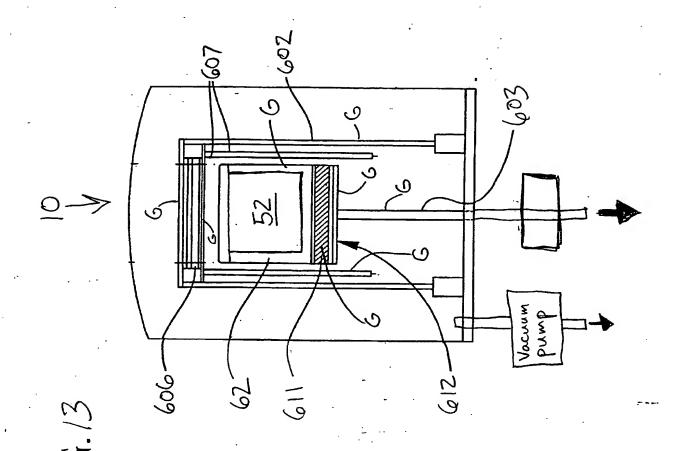
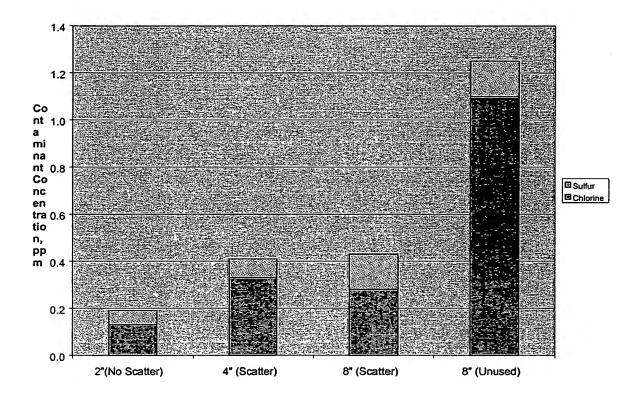


FIG. 14



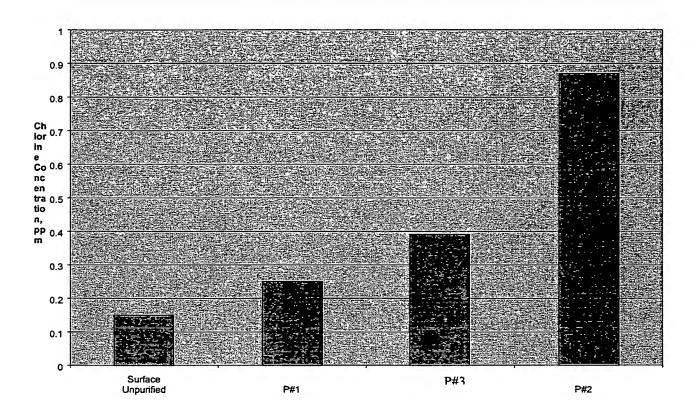


FIG. 15

Fig. 16

